L Number	Hits	Search Text	DB	
1		electron same beam same draw\$4 same (mask reticle)	USPAT; US-PGPUB; EPO; JPO;	Time stamp 2003/04/07 08:46
2	14	(electron same beam same draw\$4 same (mask reticle)) and stress same heat\$4 same film	DERWENT; IBM_TDB USPAT; US-PGPUB; EPO; JPO;	2003/04/07 08:47
5			DERWENT; IBM TDB	
	225	250/400	USPĀT; US-PGPUB	2003/04/07 09:58
6	19	250/400 and stress	USPAT; US-PGPUB	2003/04/07 09:59
-	0	09/606679	USPAT;	2003/04/06 18:07
-	0	"09606679"	US-PGPUB USPAT;	2003/04/06 18:10
_	1034	electron same beam same draw\$4 same mask	US-PGPUB USPAT;	2003/04/06 20:04
-	1421	electron same beam same draw\$4 same mask	US-PGPUB USPAT;	2003/04/06 18:11
			US-PGPUB; EPO; JPO; DERWENT; IBM TDB	
-	235	(electron same beam same draw\$4 same mask) and scatter\$4	USPAT; US-PGPUB; EPO; JPO; DERWENT:	2003/04/06 18:11
_	40	(electron same beam same draw\$4 same mask) same scatter\$4	IBM_TDB USPAT; US-PGPUB; EPO; JPO; DERWENT;	2003/04/06 20:02
-	37 '	((electron same beam same draw\$4 same mask) same scatter\$4) and pattern	IBM_TDB USPAT; US-PGPUB; EPO; JPO; DERWENT;	2003/04/06 19:07
- j	1	1999-435682.NRAN.	IBM_TDB DERWENT	2003/04/06 19:02
-		11176720.URPN.	USPAT	2003/04/06 19:02
-	2	(("5466904") or ("5260151")).PN.	USPAT; US-PGPUB	2003/04/06 19:07
-		electron same beam same draw\$4 same mask.ti.	USPAT; US-PGPUB	2003/04/06 19:13
-	5	((electron same beam same draw\$4 same mask) same scatter\$4) and stop	USPAT; US-PGPUB; EPO; JPO; DERWENT;	2003/04/06 20:02
_		electron same beam same draw\$4 same (mask reticle)	IBM_TDB USPAT; US-PGPUB	2003/04/06 20:05